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Micromachines Research and Development in North America

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Message from the Guest Editors

Dear Colleagues,

The objective of this Special Issue is to showcase the latest advances in micromachines and devices in the US and Canada, with the aim of highlighting cutting-edge research and exploring emerging trends in the field. The Special Issue welcomes reviews, original research articles, and communications in the field of micromachines, ultimately providing investigators from the US and Canada with an opportunity to present their exciting, novel research results.

The contributions to this Special Issue will highlight the current frontiers in the fields of micro-/nano-sciences, devices, and applications.

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Editor-in-Chief

Message from the Editor-in-Chief

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